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Sheet

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|------------------------|----------------------------|--|--|--|--|
| Application Number | 10/046,346 | | | | |
| Filing Date | October 26, 2001 | | | | |
| First Named Inventor | Joseph J. Sumakeris et al. | | | | |
| Group Art Unit | 2832 2811 | | | | |
| Examiner Name | G. Munson | | | | |
| Attorney Docket Number | 5000.221 | | | | |

| | | OTHER PRIOR ART NON PATENT LITERATURE DOCUMENTS | | |
|------------------------|---|---|-------|--|
| Examiner Initials * | Cite No. Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issu number(s), publisher, city and/or country where published. | | | |
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| | Examiner Signature | Ġ, | MUNSON | Date Considered | 23 APRIL | 2004 |

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